

Photomicrography

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Photomicrography

Exposure meter positions:	at	Camera type	Index Number
on the same tube as the		Miniature camera	15
camera (or on the corres- ponding inclined monocu- lar tube if the light beam		Kam "VBX"	19
is not split)		"KINEKONNEX"	4
Binocular body on "ZETOPAN", "NEOZET", "BIOZET", inclined tube of "BIOZET" triocular body	Vertical photo tube	Miniature camera	8
		Kam *VBX"	12
Binocular body on "CSM"	Vertical photo tube	Miniature camera	6
		Kam "VBX"	10
Binocular body on "Me F"	Photo tube of	Miniature camera	4
	lateral deviating prism	Kam "VBX"	8
		Built-in camera, lateral or vertical extension camera (e.g. "Me F", "Me A" or "Kam B")	
Any monocular body		Length of bellows (mm)	
		375-400	24
		400-450	25
		450-500	26
		500-550	27
	Trace K	Index number increased by 1 for each additional 50 mm bellows length.	

Low-power photomicrography on the Me F

"REMIPHOT"		Photographic System			
position	setting of eyepiece ring (4)	Objective	built-in or lateral (MeFA) camera Length of bellows (mm)	Index Number	
Inclined mono- cular tube	4x	Dallmeyer f=25 mm Neupolar f=50 mm		15	
Phototube of lateral deviating prism	6,3×	Neupolar f=100 mm		16	

Cinemicrography

In 16 mm cinemicrography on the "ZETOPAN" the exposure meter can be mounted with an intermediate tube directly on the "KINEKONNEX" cinemicrographic fitting. In the case of the "Me F" the "REMIPHOT" is inserted into the inclined monocular tube of the microscope or into the phase contrast equipment.

The exposure time of the camera shutter is determined by the film speed selected (frames per second), and the intensity of the microscope illumination must therefore be adjusted until the exposure meter indicates this fixed exposure time. During this adjustment the eyepiece ring has to be set to 10X, and the index ring to 4 in accordance with the table.